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Docket: 0756-1614

IN THE UNITED STATES PATENT AN	ID TRADEMARK OF FICE
In re Continuation Application of)
Takeshi FUKUNAGA et al.)
Based On Serial No. 08/519,420) Art Unit: 1112
Which Was Filed: August 25, 1995) Examiner: M. Padgett
For: METHOD OF MANUFACTURING)
A SEMICONDUCTOR DEVICE) Date: December 30, 1996

PRELIMINARY AMENDMENT

Honorable Assistant Commissioner for Patents

Washington, D.C. 20231

Sir:

Please preliminarily amend the subject application as follows:

IN THE CLAIMS:

Please amend claims 1 and 2 as follows:

1. (Three Times Amended) A method for manufacturing a semiconductor device, comprising the steps of:

irradiating a non-single crystalline silicon film with laser light, to crystallize the non-single crystalline silicon film;

thermally annealing the non-single crystalline silicon film in the temperature range of 450-750°C [under a nitrogen atmosphere] to decrease a

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